

## 國立中山大學100學年度碩士班招生考試試題

科目：半導體概論【電機系碩士班甲組】

1. The lattice constant of Ge is  $5.65 \times 10^{-8}$  cm for a diamond crystal structure. Calculate
  - (a) the distance from the center of one Ge atom to the center of its nearest neighbor. (10%)
  - (b) the number density of Ge atoms on  $\langle 110 \rangle$  plane ( # per  $cm^2$  ) (10%)
2. An Au-n-GaAs Schottky Contact is at  $T=300K^{\circ}$  with  $N_d=2 \times 10^{16} cm^{-3}$  ( $\phi_m=5.1$  Volt,  $\chi=4.07$  Volt,  $N_c=4.7 \times 10^{17} cm^{-3}$ ,  $\epsilon=13.1\epsilon_o$ ,  $\epsilon_o=8.85 \times 10^{-14} F/cm$ ). Calculate
  - (a) the depletion region width for a reverse bias voltage of 0.5V. (10%)
  - (b) the maximum electric field in the above condition. (10%)
3. Consider the p-n-p bipolar junction transistor with base width  $W_b$ . The base doping concentration is  $N_d$  and the base hole diffusion coefficient is  $D_p$ . The emitter doping concentration is  $N_a$ , the emitter electron diffusion coefficient is  $D_n$ , and the emitter width is  $W_e$  which is much smaller than the electron diffusion length in the emitter. Derive the expression of the emitter injection efficiency  $\gamma$ . (20%)
4. A MOS transistor is fabricated on a p-type silicon substrate with  $N_a=3 \times 10^{15} cm^{-3}$ . The oxide thickness is  $t_{ox}=600 \times 10^{-8}$  cm and the equivalent fixed oxide charge is  $Q'_{SS}=1.5 \times 10^{11} cm^{-2}$ . Calculate the threshold voltage when the source/bulk bias voltage  $V_{SB}$  is equal to 0.6 V for an  $n^+$ -polysilicon gate. ( Si :  $n_i=1.5 \times 10^{10} cm^{-3}$ ,  $\epsilon_{Si}=11.8 \epsilon_o$ ,  $\epsilon_{SiO_2}=3.9 \epsilon_o$ ,  $\epsilon_o=8.85 \times 10^{-14} F/cm$ ,  $E_g=1.12eV$ . Note:  $kT/q=0.0259$  V,  $q=1.6 \times 10^{-19} C$  ) (20%)
5. A direct semiconductor has the recombination rate  $R=\alpha (pn-n_i^2)$  where  $\alpha=1 \times 10^{-8} cm^3/s$  and  $n_i=10^{10} cm^{-3}$ . The semiconductor is doped with  $N_d=2 \times 10^{15} cm^{-3}$ . The sample is uniformly exposed to a steady optical generation rate of  $g_{op}=1 \times 10^{22} EHP/cm^3$ -s. For this excitation, calculate the electron concentration  $n$ . (20%)